L	Hits	Search Text	DP	m
Number	111.03		DB	Time stamp
-	1	("6381025").PN.	USPAT;	2003/06/18
_	1	("5325170").PN.	US-PGPUB	12:38
		( 3323170 ).PN.	USPAT; US-PGPUB	2003/06/18
-	0	6381025.URPN.	USPAT	2003/06/18
			332111	12:37
-	44	(356/481).CCLS.	USPAT;	2003/06/18
_	178	/256/517) core	US-PGPUB	12:38
-	178	(356/517).CCLS.	USPAT;	2003/06/18
_	4	5325170.URPN.	US-PGPUB USPAT	13:36 2003/06/18
			OSTAT	13:22
-	504734		USPAT;	2003/06/18
		interference or interferometer or	US-PGPUB	14:06
_	68534	interferometric or interferometrically refractive adj (index or indexing)	IICDAM.	2002/06/10
		Tellactive adj (lindex of lindexing)	USPAT; US-PGPUB	2003/06/18
-	646931	substrate or mask or wafer	USPAT;	2003/06/18
		ļ, , ,	US-PGPUB	14:07
-	4033	backscatter or (back adj scatter)	USPAT;	2003/06/18
_	23338	(interfer or interfere or interfering or	US-PGPUB	14:07
		interference or interferometer or	USPAT; US-PGPUB	2003/06/18 -
]		interferometric or interferometrically)	OB TOTOB	15.50
		and (refractive adj (index or indexing))		
-	270	((interfer or interfere or interfering or	USPAT;	2003/06/18
		interference or interferometer or interferometric or interferometrically)	US-PGPUB	13:38
		and (refractive adj (index or indexing)))		
		and (backscatter or (back adj scatter))		
-	121	(((interfer or interfere or interfering	USPAT;	2003/06/18
		or interference or interferometer or	US-PGPUB	13:38
		<pre>interferometric or interferometrically) and (refractive adj (index or indexing)))</pre>		
		and (backscatter or (back adj scatter)))		
		and (substrate or mask or wafer)		
-	68670	interfer or interfere or interfering or	EPO; JPO;	2003/06/18
		interference or interferometer or interferometric or interferometrically	IBM_TDB	14:06
<b> </b>	33672	refractive adj (index or indexing)	EPO; JPO;	2003/06/18
			IBM TDB	14:07
-	613256	substrate or mask or wafer	EPO; JPO;	2003/06/18
	242	hashanathan an () 1 1	IBM_TDB	14:07
_	243	backscatter or (back adj scatter)	EPO; JPO;	2003/06/18
_	9384	(refractive adj (index or indexing)) and	<pre>IBM_TDB EPO; JPO;</pre>	14:07
		(substrate or mask or wafer)	IBM TDB	14:07
-	0	((refractive adj (index or indexing)) and	EPO; JPO;	2003/06/18
		(substrate or mask or wafer)) and (backscatter or (back adj scatter))	IBM_TDB	14:07
_	9384	((refractive adj (index or indexing)) and	EPO; JPO;	2003/06/18
	- 50.	(substrate or mask or wafer)) and	IBM TDB	14:07
		(substrate or mask or wafer)		
-	618	((refractive adj (index or indexing)) and	EPO; JPO;	2003/06/18
		(substrate or mask or wafer)) and (interfer or interfere or interfere or interfering or	IBM_TDB	14:08
		interfer or interfere or interfering or interference or interferometer or		
		interferometric or interferometrically)		
-	0	(((refractive adj (index or indexing))	USPAT;	2003/06/18
		and (substrate or mask or wafer)) and	US-PGPUB	14:08
		(interfer or interfere or interfering or interference or interferometer or		
		interference or interferometer or interferometrically))		
		and (backscatter or (back adj scatter))	ļ	